



Technical Data Sheet

80-175 High Gloss Anti-Hologram Polish

Characteristics:

Q 80-175 HIGH GLOSS ANTI-HOLOGRAM POLISH is the latest generation machine micro-polish for the permanent removal of streaks, holograms, fine scratches and sanding marks to P3000 grain size on all paint systems (including scratch-resistant). Through the use of highly specialised, extremely homogenous abrasive bodies, a brilliant permanent high gloss finish is created under extreme light conditions even on dark and similarly sensitive shades. Holograms and fine scratches are eliminated mechanically and not, which is often the case, covered over. Q 80-175 HIGH GLOSS ANTI-HOLOGRAM POLISH is extremely economical, easy to polish and removable without leaving traces.

Application:

For optimum results we recommend using our anti-hologram pad and an orbital polisher with forced rotation.

Alternatively a rotary polisher can be used in combination with our anti-hologram pad.

Before use, moisten dried or new pads completely with polish.

With the machine switched off, apply the polish evenly over the surface to be treated and then polish crosswise with medium pressure until a transparent film appears, ie, until the aluminium oxide in the polish has completely broken down.

Do not use pads used with this product for other products. For non-scratch and groove-free removal of polish residues we recommend our non-chainstitched Profi microfibre cloth that has been ultrasonically cut.

Note:

Shake before using. Protect against frost and excessive heat. Before using, check suitability and compatibility. Do not use on hot surfaces.



This data sheet is for information purpose only. To our knowledge the data provided complies with the latest standard and is based on years of experience in the manufacturing of our products.

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